

Form PTO-1449

INFORMATION DISCLOSURE CITATION  
IN AN APPLICATION.

MAY 06 2004 (Use several sheets if necessary)

Docket Number (Optional)

CS-03-023

Application Number

10/776,793

Applicant

Indrajit Manna et al.

Filing Date

02/11/04

Group A1 Unit

2826

## U. S. PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	TITLE	CLASS	SUBCLASS	FILED DATE IF APPROPRIATE
IKQ/	6610262	8/26/03	Peng et al.	423	197	3/4/02
	6605493	8/12/03	Yu	438	135	8/29/01
	6580184	6/17/03	Song	307	112	5/16/02
	6534834	3/18/03	AshTon et al.	257	355	12/19/01
	5159518	10/27/92	Roy	361	56	1/17/90
V	5629544	5/13/97	Voldman et al.	257	355	4/25/95
IKQ/	5453384	9/26/95	Chatterjee	437	6	3/25/94

## FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

IKQ/	US Patent App. Pub. US 2003/0016479 A1 to Song, Pub. Date 1/23/03, Filed 5/16/02, US Cl. 361/56.
IKQ/	S. Voldman et al., "Electrostatic Discharge (ESD) Protection in Silicon-on-Insulator (SOI) CMOS Technology with Aluminum and Copper Interconnects in Advanced Microprocessor Semiconductor Chips"; EOS/ESD Symposium 99-105, 2A.6.1 to 2A.6.11.

EXAMINER

/Kevin Quinto/

DATE CONSIDERED

03/12/2007

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through  
citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

